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(54) Title: OPTICAL ARTICLE INCLUDING AN ANTIREFLECTING COATING HAVING ANTIFOG PROPERTIES AND PROCESS FOR MAKING SAME

(57) Abstract: An optical article comprising a substrate and on at least one face of the substrate a multilayered antireflecting coating functioning in an interferential manner having antifog properties, said antireflecting coating including a last layer with a refractive index $n \leq 1.55$ and a physical thickness of 120 nm or less directly deposited on a high refractive index layer (HI layer) having a refractive index $n > 1.55$, and a thickness of less than 500 nm.

OPTICAL ARTICLE INCLUDING AN ANTIREFLECTING COATING HAVING ANTIFOG PROPERTIES AND PROCESS FOR MAKING SAME

BACKGROUND OF THE INVENTION

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1 – FIELD OF THE INVENTION

The invention relates to an optical article including a multilayered antireflecting coating wherein the last layer of the multilayered antireflecting coating has antifog properties.

10 The invention is based on the use of a layer-by-layer (LbL) coating to form the outermost layer of a multilayered antireflecting coating, said LbL coating comprising a superabsorbent polymer and being crosslinked to get a defined refractive index range.

2 – DESCRIPTION OF RELATED ART

15 It has always been difficult in the past to obtain coatings having at the same time good antifog properties and good antireflective properties.

US patents 5,753,373, 5,873,931 and 5,997,621 disclose single antifog antireflection coatings made through sol-gel process of different surfactants, colloidal silica and crosslinking agent. However, such dip coated thin monolayer can hardly lead to a uniform antireflective (AR) 20 function over an entire substrate and the antireflective performance is then limited to a quaterwave layer, with relatively high reflection level and low control of the residual color.

US patents 6,958,172 and 7,153,584 disclose antifog antireflection coatings made through vacuum deposition of inorganic stacks with the last layer containing a mixture of inorganic silica, alumina and an organic compound having a hydrophilic group.

25 However, it is very difficult in practice to accurately control the deposition of the organic/inorganic hybrid layer in the desired ratios due to the concomitant evaporation of an organic material and an inorganic material. This process is difficult to use on an industrial scale.

Besides, the corresponding coatings become foggy upon rubbing.

30 In WO 2007/098843 and EP 1 987 378 there is disclosed a new concept for creating an antifog antireflection coating which comprises forming blind holes from the top of an antireflection layer to a water absorbing layer. The problem is that it is very difficult to make such small and uniform blind holes without impairing the optical and mechanical properties of the coating surface.

35 In WO 2007/056427, WO 2008/021817, US2008/0038458 there are disclosed superhydrophilic coatings formed from layer-by-layer (LbL) assembled films including nanoparticles and/or polyelectrolytes. These superhydrophilic coatings can be antifogging, antireflective or both antifogging and antireflective, especially by adjusting porosity of the coating.

40 The LbL coatings having antifogging and antireflective properties have generally a high porosity and a very low refractive index.

US2008/0038458 states that “a porous material can promote infiltration of water droplet into pores (to prevent fogging) and the pores can also reduce the refractive index of the coating so that it acts as an antireflecting coating”.

In the above cited patent application, a typical refractive index range is disclosed for a 5 LbL coating obtained from positively charged TiO_2 nanoparticles and negatively charged SiO_2 nanoparticles layers alternately deposited. The refractive index of the LbL made of alternately deposited charged $\text{SiO}_2/\text{TiO}_2$ layers ranges typically from 1.28 to 1.32.

In US 2007014922, the disclosed range of refractive index for PAH (poly(allylaminehydrochloride)) / SiO_2 LbL (calcinated or not) is 1.24 to 1.32.

10 According to the above patent applications, an antireflective coating is obtained by depositing the LbL coating as a monolayer on a substrate.

In US patent 2009/0324910, there is disclosed a nanoporous coating including a first thickness having a first porosity and a second thickness having a second porosity.

15 The two porous layers of these coatings are made by a LbL process, using inorganic particles having different sizes. Differentially sized nanoparticles can pack so as to have different refractive indices.

Due to their high porosity, such antifog LbL coatings have poor mechanical properties.

20 Such highly porous antifog coatings show either poor adhesion, poor durability when formed on ophthalmic lenses made of organic glass or on hard coats classically formed on such ophthalmic lenses.

Further, it is usually difficult to design a durable antireflective stack having antifog properties through such a layer-by-layer process.

25 Sundareshan, in a thesis report entitled “influence of counter ions on antifogging coatings” having a “library” date June 18, 2008, available on the MIT website, has studied the influence of counterions on $\text{ApSiO}_2/\text{PAA}$ LbL systems (ApSiO_2 designates aminopropyl functionalized silica and PAA designates poly(acrylic acid)).

Indeed, such systems do not have yet sufficient long-lasting antifog properties.

30 The refractive index of a 114 to 129 nm thickness $\text{ApSiO}_2/\text{PAA}$ coatings has been modified by treating them with salt solutions of monovalent and divalent cations, namely sodium, lithium, potassium, calcium and barium salts.

The refractive indices of the $\text{ApSiO}_2/\text{PAA}$ coatings are decreased from 1.43 (unaltered LbL coating) to around 1.34-1.35 by the treatment with monovalent cations (Na^+ , Li^+ , K^+) and were increased to 1.47-1.50 by the treatment with divalent cations (Ca^{2+} , Ba^{2+}).

35 Sundareshan suggested that the divalent cations may provide a source of internal crosslinking between NH_2 and COOH groups, which can enhance the mechanical stability of the obtained $\text{ApSiO}_2/\text{PAA}$ LbL coatings.

Sundareshan noticed, however, that the treatment with such divalent cations, promoting crosslinking, decreases the hydrophilic properties and antifog properties compared to the initial non treated $\text{ApSiO}_2/\text{PAA}$ coatings.

40 There is still a need to provide novel antireflective coatings having antifog properties and

having at the same time very good antireflective properties and mechanical properties versus the highly porous monolayered or bilayered AR LbL coatings of the prior art.

It is also desirable to provide a process for obtaining said antireflecting coating having antifog properties which involves only slight modifications of processes that are currently and 5 widely used to make AR coatings in the field of ophthalmic lenses.

SUMMARY OF THE INVENTION

An object of the invention is to provide a multilayered antireflective coating having 10 antifog properties along with good mechanical properties.

Another object of the invention is to provide an antireflective anti-fog multilayered coating able to withstand dry wiping.

A further object of the invention is to provide a process for making a multilayered antireflective coating having antifog properties as above without requiring a calcination step.

15 The optical articles of the invention show low reflection, good antifog properties and good mechanical durability.

Therefore, according to the present invention, there is provided an optical article, in particular an ophthalmic lens such as a spectacle eyeglass, comprising a substrate and on at least one face of the substrate a multilayered antireflecting coating functioning in an 20 interferential manner, having antifog properties, said antireflecting coating including a last layer with a refractive index $n \leq 1.55$ and a physical thickness of 120 nm or less directly deposited on a high refractive index layer (HI layer) having a refractive index $n > 1.55$ and a thickness of less than 500 nm, wherein :

- the last layer comprises a layer-by-layer (LbL) coating exposed to environment,

25 - the LbL coating consists in at least two bilayers, each bilayer being formed by successively

(a) applying a first layer composition comprising at least one compound A having a first electrical charge;

(b) applying a second layer composition directly on the first layer resulting from step (a),

30 said second layer composition comprising at least one compound B having a second electric charge which is opposite to said first electric charge;

compounds A and B being independently chosen from superabsorbent polyelectrolytes, colloids of nanoparticles of metal oxide or silicon oxide, or mixtures thereof, said nanoparticles comprising ionic groups and said compounds A and B being functionalized by either $-NH_2$ or $-$

35 COOH functional groups, with the first proviso that at least one of compounds A or B is a superabsorbent polyelectrolyte, and with the second proviso that the layers of the antireflecting coating other than the last layer do not comprise any bilayer formed from compositions having opposite electrical charges, and

- the LbL coating is crosslinked through chemical linkages between said $-NH_2$ and $-$

COOH groups and has a refractive index at 643 nm ranging from 1.40 to 1.50, preferably from more than 1.43 to 1.49.

In one embodiment of the present invention, the last layer of the antireflective coating consists exclusively in a LbL coating.

5 In the other embodiment of the present invention, the last layer of the antireflective coating is a composite layer comprising a metal oxide or silicon oxide layer having a refractive index $n \leq 1.55$ and preferably ranging from 1.40 to 1.50, underlying a LbL layer as defined above.

10 The present invention also concerns a process for making a multilayered antifogging antireflecting coating functioning in an interferential manner onto an optical substrate comprising:

(i) providing an uncoated or coated substrate ;

(ii) forming on said substrate at least one high refractive index layer (HI layer) having a refractive index $n > 1.55$ and a thickness lower than 500 nm ;

15 (iii) forming on the HI layer resulting from step (ii) a last layer with a refractive index $n \leq 1.55$ and a physical thickness of 120 nm or less comprising a LbL coating which comprises at least two bilayers, each bilayer being formed by :

(a) applying a first layer composition comprising at least one compound A having a first 20 electrical charge;

(b) applying a second layer composition directly on the first layer resulting from step (a), said second layer composition comprising at least one compound B having a second electric charge which is opposite to said first electric charge;

25 compounds A and B being independently chosen from superabsorbent polyelectrolytes, colloids of nanoparticles of metal oxide or silicon oxide, or mixtures thereof, said nanoparticles comprising ionic groups and said compounds A and B being functionalized by either NH_2 or COOH groups with the proviso that at least one of compounds A or B is a superabsorbent polyelectrolyte,

(c) repeating at least once steps (a) and (b),

30 (d) at least partially drying the LbL coating resulting from step c) and

(e) crosslinking the first and second layers of the bilayers of the LbL coating by treatment with a coupling agent in an aqueous based solvent inducing chemical linkages between said NH_2 and COOH groups of compounds A and B, said crosslinking step being performed after step (d), so that the resulting LbL coating has a refractive index at 643 nm ranging from 1.40 to 35 1.50.

In a further embodiment of the invention, the process for making an antireflective and antifog coating comprises applying metal oxide or silicon oxide to form a low refractive index layer (LI layer) having a refractive index $n < 1.55$ on the high refractive index layer prior to forming the LbL layer.

In general, and preferably the metal oxide and silicon oxide layers are deposited by vacuum deposition and the LbL layers are deposited by dip coating or spin coating, preferably by dip coating.

5 BRIEF DESCRIPTION OF THE DRAWINGS

The foregoing and other objects, features and advantages of the present invention will become readily apparent to those skilled in the art from a reading of the detailed description hereafter when considered in conjunction with the accompanying figures, wherein :

10 Figures 1A, 1B and 1C schematically represent hard coated lenses provided with different designs of an antifog antireflecting coating according to the invention;

Figures 2A and 2B are relative transmission (Tr) graphs of different antifog antireflecting coatings, compared with an Essilor reference lens (Ref.), measured by the EN 168 Standard fog test.

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DETAILED DESCRIPTION OF THE INVENTION AND PREFERRED EMBODIMENTS

The terms "comprise" (and any grammatical variation thereof, such as "comprises" and "comprising"), "have" (and any grammatical variation thereof, such as "has" and "having"), 20 "contain" (and any grammatical variation thereof, such as "contains" and "containing"), and "include" (and any grammatical variation thereof, such as "includes" and "including") are open-ended linking verbs. They are used to specify the presence of stated features, integers, steps or components or groups thereof, but do not preclude the presence or addition of one or more other features, integers, steps or components or groups thereof. As a result, a method, or a step 25 in a method, that "comprises," "has," "contains," or "includes" one or more steps or elements possesses those one or more steps or elements, but is not limited to possessing only those one or more steps or elements.

Unless otherwise indicated, all numbers or expressions referring to quantities of ingredients, ranges, reaction conditions, etc. used herein are to be understood as modified in all 30 instances by the term "about."

When an optical article comprises one or more surface coatings, the phrase "to deposit a coating or layer onto the optical article" means that a coating or layer is deposited onto the outermost coating of the optical article, i.e. the coating which is the closest to the air.

A coating that is "on" a side of a lens is defined as a coating that (a) is positioned over 35 that side, (b) is not necessary (but preferably) in contact with that side, i.e., one or more intervening coatings may be disposed between that side and the coating in question, and (c) does not need to cover that side completely.

As used herein, the phrase "last layer" means a monolayer or a multilayer which is in contact with the environmental air.

40 The phrase "functioning" in an interferential manner intends to exclude the case wherein

the antireflective effect is principally due to an index gradient of the LbL layer, i.e. the case wherein the LbL layer is antireflective by itself.

Even if the presence of a gradient cannot be fully excluded, the invention uses the refractive index of the LbL and its thickness in the interferential system constituted by the 5 multilayered antireflective coating.

In a preferential embodiment, there is no refractive index gradient inside the LbL layer.

The optical article prepared according to the present invention is a transparent optical article, preferably a lens or lens blank, and more preferably an ophthalmic lens or lens blank. The optical article may be coated on its convex main side (front side), concave main side (back 10 side), or both sides using the process of the invention.

Herein, the term "lens" means an organic or inorganic glass lens, comprising a lens substrate which may be coated with one or more coatings of various natures.

The lens substrate may be made of mineral glass or organic glass, preferably organic glass. The organic glasses can be either thermoplastic materials such as polycarbonates and 15 thermoplastic polyurethanes or thermosetting (cross-linked) materials such as diethylene glycol bis(allylcarbonate) polymers and copolymers (in particular CR-39[®] from PPG Industries), thermosetting polyurethanes, polythiourethanes, polyepoxides, polyepisulfides, poly(meth)acrylates and copolymers based substrates, such as substrates comprising (meth)acrylic polymers and copolymers derived from bisphenol-A, polythio(meth)acrylates, as 20 well as copolymers thereof and blends thereof. Preferred materials for the lens substrate are polycarbonates (PC) and diethylene glycol bis(allylcarbonate) polymers, in particular substrates made of polycarbonate.

The surface of the article onto which the antifog antireflecting coating will be applied may 25 optionally be subjected to a pre-treatment step intended to improve adhesion, for example a high-frequency discharge plasma treatment, a glow discharge plasma treatment, a corona treatment, an electron beam treatment, an ion beam treatment, an acid or base treatment.

The antifog antireflecting coating of the invention may be deposited onto a naked substrate or onto the outermost coating layer of the substrate if the substrate is coated with at 30 least one surface coating. Said at least one surface coating may be, without limitation, an impact-resistant coating (impact resistant primer), an abrasion and/or scratch resistant coating, a polarized coating, a photochromic coating or a dyed coating.

The impact-resistant coating which may be used in the present invention can be any coating typically used for improving impact resistance of a finished optical article. This coating generally enhances adhesion of the abrasion and/or scratch-resistant coating on the substrate 35 of the finished optical article. By definition, an impact-resistant primer coating is a coating which improves the impact resistance of the finished optical article as compared with the same optical article but without the impact-resistant primer coating.

Typical impact-resistance primer coatings are (meth)acrylic based coatings and 40 polyurethane based coatings, in particular coatings made from a latex composition such as a poly(meth)acrylic latex, a polyurethane latex or a polyester latex.

Polyurethane-polyester latexes are commercially available from ZENECA RESINS under the trade name Neorez® (e.g., Neorez® R-962, Neorez® R-972, Neorez® R-986, Neorez® R-9603) or BAXENDEN CHEMICALS, a subsidiary of WITCO Corporation, under the trade name Witcobond® (e.g., Witcobond® 232, Witcobond® 234, Witcobond® 240, Witcobond® 242).

5 The abrasion- and/or scratch-resistant coating which may be used in the present invention can be any coating typically used for improving abrasion- and/or scratch-resistance of a finished optical article as compared to a same optical article but without the abrasion- and/or scratch-resistant coating.

10 Preferred abrasion- and/or scratch-resistant coatings are (meth)acrylate based coatings and silicon-containing coatings, more specifically coatings based on a hydrolyzate of epoxypolyalkoxysilanes. The latter are more preferred and some of them are disclosed, for example, in French patent application FR 2702486, which is incorporated herein by reference.

15 The antifog antireflective coating of the invention comprises, starting from the naked or coated substrate, at least one high refractive index layer (HI layer) having a refractive index $n > 1.55$, preferably a stack of high refractive index layers and low refractive index layers (LI layers) of refractive index $n \leq 1.55$ and a last layer, directly formed on a HI layer which comprises a LbL layer exposed to environment (air).

The layers of the antireflecting coating other than the last layer do not comprise any bilayer formed from compositions having opposite electrical charges.

20 The refractive indices are measured by infrared ellipsometer at 634 nm. This method is disclosed in A. BRUNET-BRUNEAU, S. FISSON, G. VUYE, J. RIVORY, J. Appl. Phys. 2000, 87, 7303-7309, and A. BRUNET-BRUNEAU, S. FISSON, B. GALLAS, G. VUYE, J. RIVORY, Thin Solid Films, 2000, 377, 57-61.

25 As used herein, a low refractive index layer is intended to mean a layer with a refractive index n of 1.55 or less, preferably lower than 1.50 and even better lower than 1.45 and preferably ranging from 1.40 to 1.50, and a high refractive index layer is intended to mean a layer with a refractive index n higher than 1.55, preferably higher than 1.6, more preferably higher than 1.8 and even better higher than 2.

30 HI layers are classical high refractive index layers and may comprise, without limitation, one or more mineral oxides such as TiO_2 , PrTiO_3 , LaTiO_3 , ZrO_2 , Ta_2O_5 , Y_2O_3 , Ce_2O_3 , La_2O_3 , Dy_2O_5 , Nd_2O_5 , HfO_2 , Sc_2O_3 , Pr_2O_3 or Al_2O_3 , or Si_3N_4 , as well as mixtures thereof, preferably ZrO_2 , TiO_2 or PrTiO_3 . HI layers may optionally contain low refractive index materials such as SiO_2 . Obviously, mixtures of those compounds are such that the refractive index of the resulting layer is as defined above (higher than 1.55).

35 LI layers are also well known and may comprise, without limitation, SiO_2 , SiO_x with $1 \leq x < 2$, MgF_2 , ZrF_4 , Al_2O_3 , AlF_3 , chiolite ($\text{Na}_5\text{Al}_3\text{F}_{14}$), cryolite (Na_3AlF_6), or mixtures thereof, preferably SiO_2 or SiO_2 doped with Al_2O_3 which contributes to raising the critical temperature of the stack. Obviously, mixtures of those compounds are such that the refractive index of the resulting layer is as defined above (lower than or equal to 1.55). When $\text{SiO}_2/\text{Al}_2\text{O}_3$ mixtures are used, the LI layer preferably contains from 1 to 10%, more preferably from 1 to 8% by weight of

Al_2O_3 relative to the total weight of $\text{SiO}_2 + \text{Al}_2\text{O}_3$ in said layer. A too high amount of alumina is detrimental to the adhesion of the AR coating.

For example, SiO_2 doped with 4% or less Al_2O_3 by weight, or SiO_2 doped with 8% Al_2O_3 by weight may be employed. Commercially available $\text{SiO}_2/\text{Al}_2\text{O}_3$ mixtures can also be employed, such as LIMA® supplied by Umicore Materials AG (refractive index $n = \sim 1.48$ at 550 nm), or substance L5® supplied by Merck KGaA (refractive index $n = 1.48$ at 500 nm). The most preferred material for LI layers is SiO_2 doped with 8% Al_2O_3 by weight.

Generally, HI layers and LI layers, have a physical thickness, ranging from 10 to 120 nm (HI) and 10 to 100 nm (LI), respectively.

10 The antireflecting stack of the present invention may include any layer or stack of layers which improves the antireflective properties of the finished optical article over at least one portion of the visible spectrum, thereby increasing the transmission of light and reducing surface reflectance.

15 Preferably, the multilayered antireflecting stack comprises, in addition to the innermost and outermost layers, at least one LI layer and at least two HI layers. Preferably, the total number of layers in the anti-reflection coating is ≤ 9 , preferably ≤ 7 .

20 LI and HI layers are not necessarily alternated in the AR stack, although the anti-reflection coating may comprise an alternated stack of low refractive index and high refractive index layers according to a particular embodiment of the invention. Two or more HI layers may be deposited on one another; two or more LI layers may be deposited on one another.

In general, the total thickness of the antireflecting stack is less than 1.5 μm , preferably 1 μm or less, and even better 0.5 μm or less, and generally ranging from 0.2 to 0.5 μm .

The HI and LI layers are generally applied by vacuum deposition according to one of the following techniques:

25 1) - by evaporation, optionally ion beam-assisted;
2) - by spraying using an ion beam,
3) - by cathode sputtering; or
4) - by plasma-assisted vapor-phase chemical deposition.

30 These different methods are described in "Thin Film Processes" and "Thin Film Processes II", Vossen & Kern, Ed., Academic Press, 1978 and 1981, respectively. Said evaporation under vacuum is a particularly recommended method.

35 These layers can also be applied by applying liquid solutions, preferably by a spin coating process. However, the layers of the antireflecting coating other than the last layer do not comprise any bilayer formed from compositions having opposite electrical charges. Preferably, such solutions do not contain superabsorbent polymers.

All antireflecting coating layers, except the final LbL coating, are preferably deposited by evaporation under vacuum.

40 It is well known that optical articles tend to become charged with static electricity, particularly when being cleaned under dry conditions by rubbing their surface with a cloth, a piece of synthetic foam or polyester. They can then draw and fix the small particles in their

vicinity such as dusts, and this goes on for all the time the charge remains on the article. It is well known in the state of the art that an article may acquire antistatic properties thanks to the presence on its surface of an electrically conductive layer. This method has been applied in patent application WO 01/55752 and in patent EP 0834092.

5 An article is said to be "antistatic" when it does possess the ability not to retain and/or develop an appreciable electrostatic charge. An article is typically considered as having acceptable antistatic properties when it does not draw and fix dust as well as small particles after one of its surfaces was rubbed by means of a suitable cloth.

There are various methods for quantifying the antistatic properties of a material.

10 One of such methods does take the static potential of a material into account. When the material's static potential (as measured when the article is still uncharged) is 0 KV +/- 0.1 KV (absolute value), the material is said to be antistatic, on the contrary when its static potential is different from 0 KV +/- 0.1 KV (absolute value), the material is said to be static.

15 According to another method, the ability for a glass to discharge a static charge after rubbing with a cloth or by any other means suitable for generating an electrostatic charge (corona-applied charge) may be quantified by measuring the dissipation time of said charge. Thus, antistatic glasses do have a discharge time that is about a hundred milliseconds, while it is about several tens of seconds for a static glass.

20 The article of the invention may be made antistatic by incorporating at least one electrically conductive layer into the antireflecting stack. The electrically conductive layer may be located in various locations of the antireflecting stack, provided its antireflection properties are not impaired. It is preferably located under a low refractive index layer of the antireflecting stack.

25 The electrically conductive layer must be thin enough not to impair the transparency of the antireflection coating. Typically, its thickness does vary from 0.1 to 150 nm, more preferably from 0.1 to 50 nm, depending on its nature. When it is less than 0.1 nm thick, it does not typically enable to obtain a sufficient electrical conductivity, on the contrary when it is more than 150 nm thick, it does not typically enable to obtain the required transparency and low absorption characteristics.

30 The electrically conductive layer is preferably made of an electrically conductive and highly transparent material. In that case, its thickness does preferably vary from 0.1 to 30 nm, more preferably from 1 to 20 nm and even more preferably from 1 to 10 nm. The electrically conductive layer preferably comprises a metal oxide selected from indium, tin, and zinc oxide, as well as mixtures thereof. Indium-tin oxide ($In_2O_3:Sn$, i.e. indium oxide doped with tin) and tin oxide are preferred. According to an optimal embodiment, the electrically conductive and optically transparent layer is an indium-tin oxide layer, referred to an ITO layer.

35 Typically, the electrically conductive layer does contribute to obtain the antireflection properties and form a high refractive index layer in the antireflection coating. That is the case when layers are made of an electrically conductive and highly transparent material such as the ITO layers.

The electrically conductive layer may also be a layer made of a very thin noble metal that is typically less than 1 nm thick, more preferably less than 0.5 nm thick.

The electrically conductive layer, that is typically a high refractive index layer of the antireflection stack, may be deposited according to any suitable method, for example by 5 vacuum deposition, by evaporation, preferably by ion beam assisted deposition (IAD), or by a cathode sputtering or ion beam method.

The last layer of the multilayered antifog antireflective coating of the invention comprises a LbL coating which is in direct contact with the environmental atmosphere (usually air).

The LbL coating comprises at least two bilayers, each bilayer being formed by 10 successively

(a) applying a first layer composition comprising at least one compound A having a first electrical charge;

(b) applying a second layer composition directly on the first layer resulting from step (a), said second layer composition comprising at least one compound B having a second electric 15 charge which is opposite to said first electric charge, said compounds A and B being independently chosen from superabsorbent polyelectrolytes, colloids of nanoparticles of metal oxide or silicon oxide, or mixtures thereof, said nanoparticles comprising ionic groups and said compounds A and B being functionalized by either -NH₂ or -COOH functional groups, with the first proviso that at least one of compounds A or B is a superabsorbent polyelectrolyte, and with 20 the second proviso that the layers of the antireflecting coating other than the last layer do not comprise any bilayer formed from compositions having opposite electrical charges, and the LbL coating is crosslinked through chemical linkages between said NH₂ and COOH groups and has a refractive index at 643 nm ranging from 1.40 to 1.50

A superabsorbent polyelectrolyte is a superabsorbent polymer having a substantial 25 portion of its repeating units bearing an electrolyte group. These groups are ionic or ionisable groups especially in aqueous based solutions.

A superabsorbent polymer is a polymer forming a hydrophilic network that can absorb and retain a high amount of water, i.e. more than 100% by weight of water.

Typically, superabsorbent polymers can imbibe deionized water as high as 1,000 to 30 100,000% by weight (10 to 1000g/g).

Examples of superabsorbent polymers are poly(acrylic acid), carbohydrate polymers (polysaccharides) such as chitosan or cellulose.

According to the invention, the superabsorbent polyelectrolyte comprises free amino or acidic groups.

Preferably, the superabsorbent polyelectrolyte is a polysaccharide polymer including 35 glucosamine units, a carboxyalkyl cellulose polymer or a polyacrylic acid polymer or polyacrylic acid copolymer.

In a preferred embodiment, the LbL coating of the invention comprises at least two bilayers, each bilayer being enabled by the molecular level blending of at least two

superabsorbent polyelectrolytes which are crosslinked through chemical bondings between -NH₂ groups and -COOH groups.

In another embodiment of the present invention, compound A or B comprises silicon oxide nanoparticles, preferably functionalized with amino groups.

5 In the present invention each bilayer of the LbL coating preferably consists in:

- a) a first layer of a polysaccharide comprising glucosamine units such as chitosan (CTS) or poly(1,3- β -D-glucosamine-alt-1,4- β -D-glucuronic acid), preferably chitosan, and a second layer of a carboxyalkyl cellulose, such as carboxymethyl cellulose, carboxyethyl cellulose or carboxypropyl cellulose, preferably carboxymethyl cellulose (CMC); or
- 10 b) a first layer of an oxide of a metal or silicon which is surface functionalized with amine groups, preferably aminopropyl functionalized silica nanoparticles (ApSiO₂), and a second layer of a polymer chosen from PAA, poly(methacrylic acid) (PMAA), PAA copolymer, PMAA copolymer and mixtures thereof, preferably PAA.

15 The LbL coating application process involves the sequential dipping, spraying or spin-coating of solutions of the specific constituents. The deposition of each cycle of complementary polymers creates a "bilayer".

20 For convenience in expressing the assembled system, the following notation is commonly used: (polycation/polyanion)_n. Polycation and polyanion are the abbreviations of the specific polyelectrolytes used in the LbL assembly and n is the number of bilayers that have been deposited. For example, a ten bilayer assembly comprising CTS and CMC is noted as (CTS/CMC)₁₀. Sometimes the LbL coating may comprise one additional layer of one of the above disclosed constituents. Therefore, for example a LbL assembly of ten bilayers of CTS and CMC including one additional CTS layer is noted (CTS/CMC)_{10.5}.

25 Although the LbL coating may comprise 2 to 20 bilayers, it preferably comprises 8 to 15 bilayers and more preferably 8 to 12 bilayers.

Typically the LbL coating will have a physical thickness ranging from 30 to 120 nm, preferably from 60 to 100 nm.

, The LbL coating, after the crosslinking step, has a refractive index n ranging from 1.40 to 1.50, preferably from 1.43 to 1.49.

30 As indicated the LbL coating is crosslinked through bondings between NH₂ and COOH groups.

Before the crosslinking step, the LbL coating is at least partially dried, preferably in the air, at ambient temperature during typically 5 minutes to 1 hour, preferably 10 to 20 minutes.

35 Then the crosslinking step is classically performed by treatment with a coupling agent inducing chemical bonds between NH₂ and COOH groups. Carbodiimide coupling reagents are well known for the formation of amide linkages. Useful carbodiimide-functional compounds have formula :

40 N(CH₃)₂-(CH₂)_n-N=C=N-CH₂CH₃, wherein n is an integer from 2 to 6. Particularly, preferred compound is the compound with n=3, 1-ethyl-3 (-3-dimethylaminopropyl) carbodiimide (EDC). EDC is commercially available from TCI America. Other useful carbodiimides are N,N'-

dicyclohexylcarbodiimide and N,N'-diisopropylcarbodiimide.

These carbodiimides are often used in combination with hydroxysuccinimide, sulfohydroxysuccinimide or N-hydroxybenzotriazole to increase coupling efficiency and decrease side reactions.

5 Synthesis of carbodiimides are disclosed by Sheehan, John; Cruishank, Philip, Boshart, Gregory (1961) in "A convenient Synthesis of Water soluble Carbodiimides" J. Org.Chem. 26 (7), 2525 and by Nakajima, N; Ikada, Y (1995) in "Mechanism of Amide Formation by Carbodiimide for Bioconjugation in Aqueous Media" Bioconjugate Chem., 6 (1),123.

10 A preferred coupling agent is 1-ethyl-3-[3-dimethylaminopropyl] carbodiimide (EDC), combined with N-hydroxysuccinimide (NHS) in a buffered solution.

The process of the invention does not require any calcination step to get the advantageous properties of the final AR coating.

15 All the process steps are implemented at a temperature lower than 130 °C, preferably lower than 100 °C. More preferably, all the process steps are implemented at a temperature lower than 50 °C and better at ambient temperature.

According to the process of the invention, it is possible to accurately control the refractive index of the LbL coating comprising a superabsorbent polymer by controlling the degree of swelling of the resulting LbL coating, i.e. controlling its porosity.

20 As explained previously, superabsorbent polymers have a huge ability to swell in water. It is an important feature of the invention to limit the increase of porosity of the final LbL coating. It is possible to obtain a final refractive index close to the refractive index of silica, classically used in the common evaporated antireflective stacks.

There is consequently no need to substantially modify usual AR stacks when using the process of the invention.

25 Obviously, the process of the invention can also be used with new designed AR stacks.

The swelling of the superabsorbent polymer, and consequently the porosity of the final LbL coating, is limited by the crosslinking step of the LbL coating.

30 This control may also be achieved by adding an organic cosolvent such as an alcohol to the aqueous based solution used for the crosslinking step.

It was experimentally found that the refractive index of the final LbL coating in its crosslinked state increases when the ratio of organic solvent/water in the crosslinking solution increases.

35 The last layer of the antifog antireflecting coating of the invention can be entirely formed of a LbL coating as disclosed above or it can also be a composite layer consisting of LbL coating as above and an underlayer (between the LbL coating and a HI layer of the antifog antireflecting coating) having a refractive index $n \leq 1.55$ comprising and preferably made of metal oxide or silicon oxide, preferably SiO_2 . This underlayer generally has a physical thickness of 10 to 50 nm, preferably 10 to 30 nm, and better 10 to 20 nm. The underlayer is applied by the same processes as the usual HI and LI layers made of metal oxide and silicon oxide disclosed above. The underlayer is preferably applied by vacuum deposition.

The antifog antireflecting coating of the invention presents a good adhesion to the substrate and advantageously can withstand dry wiping without loosing its antifog properties.

The present invention will now be described with reference to the following examples.

5 EXAMPLES

1 – TESTING METHODS

10 The following test procedures were used to evaluate the optical articles according to the present invention.

(a) Fog test according to EN 168 Standard

15 The antifog properties were evaluated by an apparatus slightly modified from European Standard Test (EN 168). The ambient temperature during the measurement is $23 \pm 5^\circ\text{C}$. The temperature of the water bath is set at $50 \pm 0.5^\circ\text{C}$. The air above the water bath is circulated using a ventilator, so that it becomes saturated with water vapor. During this time, the measurement opening is to be covered. The ventilator is switched off before measurement. The samples must be placed in the test position within 2s of the opening being uncovered.

20 To measure the transmittance change, the sample is placed on the seating ring, with one side exposed to the water vapor and the upper side exposed to the air. The relative transmittance (T_r) is recorded as $T_r \% = (T_f/T_i) * 100 = (I_f/I_i) * 100$, where the initial transmittance (T_i) is determined by laser intensity (I_i) passing through the sample in the non-fogging conditions, and the transmittance (T_f) is determined by laser intensity (I_f) passing through the sample during the fogging condition. The measurement spectrum shows the change of T_r during a measurement time from 0 to 120s. An Essilor reference (Ref.) lens is used as a comparison example (5% T_r at 60s and 7% at 120s). Two T_r data at 60s and 120s of each sample are listed in the table for sample comparison.

25 The Ref. lens is a lens comprising a substrate as defined below in point "preparation of the substrate" on which have been formed by vacuum deposition, starting from the substrate, an antireflective stack comprising a first layer ZrO_2 (27 nm), a second layer SiO_2 (21 nm), a third layer ZrO_2 (80 nm), a fourth layer SiO_2 (81 nm) layer, and, on top of the antireflective stack, an antisoiling coating by evaporation under vacuum of OPTOOL DSX^(R) marketed by DAIKIN INDUSTRIES (thickness: from 2 to 5 nm).

(b) Hand wiping test

35 A coated substrate is hand-wiped with a dry microfiber cloth for 20 strokes (one stroke: one back and one forth actions). After wiping, the coated substrate is under visual inspection by two levels: 1) passed: if the coating remains the initial antireflecting color and no fog by breathing; 2) failed: if the coating loses the initial antireflecting color and appears foggy by breathing, indicating the coatings partially or completely removed.

(c) Reflectance

The mean reflectance factor R_v is such as defined in ISO standard 13666:1998 and measured in accordance with ISO standard 8980-4, i.e. it is the balanced average spectral reflection in the visible spectrum in the wavelengths limits ranging from 380 nm to 780 nm.

5 An AR coating provides $\geq R_v$ of less than 2.5% per face of a coated lens.

The mean reflectance R_m is the mean value (not balanced) of the spectral reflectance over a wavelength range 400 nm to 700 nm.

(d) Thickness

10 The thickness of the layers and films prepared on frosted glass is evaluated by infrared ellipsometer at 634 nm (thickness $< 1\mu\text{m}$) equipped with M-44TM, EC-270 and LPS-400 with 75W Xenon light source from J.A. Woolam Co. Inc.; or the thickness of the layers and films coated on lenses is measured by a Metricon Model 2010 Prism Coupler apparatus (thickness $> 1\mu\text{m}$) from Metricon Corporation.

15

2 – PREPARATION OF THE SUBSTRATE

In all examples the optical articles were round lenses (plano or – 2.00 dioptres with a diameter of 68 mm) comprising an ORMA^(R) lens substrate (obtained by polymerizing CR-39^(R) diethylene glycol bis(allyl carbonate) monomer), coated on both faces with an abrasion-resistant 20 and/or an antiscratch coating (hard coat) disclosed in example 3 of the patent EP 0614957 (refractive index 1.50, thickness 3.5 μm), based on a hydrolysate of GLYMO and DMDES, with colloidal silica and aluminum acetyl acetonate.

The abrasion-resistant coating was obtained by depositing and curing of a composition comprising by weight, 224 parts of GLYMO, 80.5 parts of HCl 0.1 N, 120 parts of DMDES, 718 25 parts of a 30 weight% colloidal silica in methanol, 15 parts of aluminum acetyl acetonate and 44 parts of ethylcellulose. The composition also comprised 0.1% of the surfactant FLUORADTM FC-430^(R) (3M) by weight as related to the total weight of the composition. This abrasion-resistant coating was deposited directly onto the substrate.

3 – ANTIFOG ANTIREFLECTING COATING DESIGNS

Three designs of antifog antireflecting coatings have been elaborated using classical software of AR modelization.

All the thicknesses of the different layers of the AR coatings have been determined 35 assuming a theoretical refractive index for the last LbL layer (refractive index considered as 1.48 (design III) or 1.50 (design I and II) at 634nm).

In the tables under 3.1 to 3.3 hereafter, there are reported the thicknesses actually (experimentally) deposited for the vacuum deposited layers and the LbL layers deposited by dip coating.

40 The layers deposited by vacuum deposition strictly correspond to the modelized layer.

The experimentally deposited LbL layers have a thickness and a refractive index slightly different from the theoretically required values.

However, as this will be demonstrated hereafter, the obtained lenses have very good AR properties.

5

3.1 – Design I (Figure 1A)

Both sides of a substrate 1 as disclosed in point 2 above were coated from bottom to top by vacuum deposition with layers 2 to 5a and by dip coating with a final LbL coating 5b.

Layer	Material	Thickness (nm)
2	ZrO ₂	26
3	SiO ₂	22
4	ZrO ₂	88
5	5a	13
	5b	85-100 nm for CTS/CMC based LbL or 70-80 nm for ApSiO ₂ /PAA based LbL

10

3.2 – Design II (Figure 1B)

Both sides of a substrate 1 as disclosed in point 2 above were coated from bottom to top by vacuum deposition with layers 2 to 4 and by dip coating with a final LbL coating 5 :

Layer	Material	Thickness (nm)
2	ZrO ₂	26
3	SiO ₂	22
4	ZrO ₂	87
5	LbL	105 nm for CTS/CMC based LbL

15

3.3 – Design III (Figure 1C)

Both sides of a substrate as disclosed in point 2 above were coated from bottom to top by vacuum deposition with layers 2 to 5 and by dip coating with LbL coating 6:

Layer	Material	Thickness (nm)
2	ZrO ₂	27
3	SiO ₂ /Al ₂ O ₃	42
4	TiO ₂	26
5	ZrO ₂	9
6	LbL	104 nm for ApSiO ₂ /PAA based LbL

20

The solid content of Al₂O₃ in the layer 3 is 8wt%.

3.4 – Application of LbL coating

Two types of layer-by-layer (LbL) coatings were applied onto these designed AR stacks.

The general process for application of LbL coating onto both sides of a substrate coated with the antireflecting mineral layers is as follow:

- I. **Surface cleaning:** The coated substrate is first dipped in an ultrasonic caustic solution, and then rinsed in ultrasonic deionized (DI) water and air dried; or treated with air or

oxygen plasma.

5 II. **Coating process:** The treated substrate is dipped in a polycation solution, followed with a rinsing step in two agitated DI water baths; and then dipped in a polyanion solution, followed with a rinsing step in two agitated DI water baths. This process is repeated for (n-1) times and the resulting coated substrate is then air dried for 20 to 30 minutes to get a coating with n bilayers of (polycation/polyanion), written as (polycation/polyanion)_n. In some cases, the polycation is further deposited as the outermost layer in the process, then the multilayer coating is then written as (polycation/polyanion)_{n+0.5}.

10 III. **Post-treatment:** After being dried as mentioned in II above, the multilayers are chemically cross-linked in a crosslinker solution, then rinsed in an ultrasonic solution and air dried.

Polycations: chitosan (CTS, low molecular weight, used at 0.1wt% in water added with 0.2wt% of acetic acid for solubility improvement, pH=4.0) and ApSiO₂ nanoparticles (15nm, 15 3.0w/v% in ethanol, used at 0.005wt% in water, pH=3.5) purchased from Sigma-Aldrich

Polyanions: sodium carboxymethyl cellulose purchased from Sigma-Aldrich (CMC, Mw=250,000, used at 0.1wt% in water, pH=4.0), polyacrylic acid purchased from Polysciences, Inc (PAA, used as 0.01M in water, pH=3.5)

Crosslinking agents: 1-Ethyl-3-[3-dimethylaminopropyl]carbodiimide hydrochloride (EDC) purchased from TCI America, N-hydroxysuccinimide (NHS) purchased from Alfa Aesar

Buffer solutions: 2-(N-Morpholino)ethanesulfonic acid (MES, 0.05M) and Phosphate buffered saline (PBS) purchased from Sigma-Aldrich

Example 1: CTS/CMC coating on Design I stack

25 0.1wt% of CTS (added with 0.2wt% of acetic acid) and 0.1% of CMC solutions were prepared with deionized (DI) water, respectively. All solutions including the DI water rinsing baths were titrated down to pH 4.0 using 0.1N HCl. The dipping time in material solutions was 5min. The rinsing time in both of agitated DI water was 2min (agitation speed is about 100rpm).

30 A LbL coating (CTS/CMC)₁₀ or (CTS/CMC)₁₁ was assembled on both sides of the Design I lens, dried and then dipped in a 0.05M MES buffer solution containing EDC (0.2M) and NHS (0.05M) for 1h, and finally rinsed by a PBS solution (0.5x) and air dried. The refractive index of the coatings was characterized as 1.51 and 1.45 at 634nm, respectively, before and after the crosslinking step, measured by ellipsometer. The thickness of the two LbL coatings was about 60nm, and increased to 85 -100 nm after the crosslinking step. The AR parameters of a 35 concave side of crosslinked samples (C1-1 &2) and the coating antifog performances are shown in the table.

Sample	Coating	Rm (%)	Rv (%)	T _r % (EN168)	
				60 s	120 s
C1-1	Crosslinked (CTS/CMC) ₁₀	0.34	0.31	72	77
C1-2	Crosslinked (CTS/CMC) ₁₁	0.71	0.33	83	85

Example 2: CTS/CMC coating on Design II stack

The procedure was same as Example 1. A LbL coating (CTS/CMC)_{12.5} was assembled 5 on both sides of the Design II lens, dried and then dipped in a 0.05M MES buffer solution (pH=5.0), containing EDC (0.2M) and NHS (0.05M) for 1h, and finally rinsed by a PBS solution (0.5x, pH=7.0) and air dried. The thickness of the crosslinked LbL coating was about 105nm and its refractive index was 1.46 in average.

Sample	Coating	Rm (%)	Rv (%)	T _r % (EN168)	
				60 s	120 s
C2-1	Crosslinked (CTS/CMC) _{12.5}	1.37	0.94	92	91

10

Example 3: ApSiO₂ /PAA coating on Design I stacks

0.05wt% of ApSiO₂ and 0.01M of PAA solutions were prepared with DI water, respectively. All solutions including the DI water rinsing baths were titrated down to the same 15 pH 3.5 using 0.1N HCl. The dipping time in material solutions was 2 min. The rinsing time in both of agitated DI water was 1min (agitation speed is about 100rpm).

The (ApSiO₂/PAA)₈ or (ApSiO₂/ PAA)_{8.5} coating was assembled on both sides of the Design I lens, dried and then dipped in a 0.05M MES buffer solution containing EDC (0.2M) and NHS (0.05M) for 1h, and finally rinsed by a PBS solution (0.5x) and air dried. The thickness of 20 two crosslinked coatings was 70-80nm and their refractive index was 1.48 in average at 634nm.

Sample	Coating	Rm (%)	Rv (%)	T _r % (EN168)	
				60 s	120 s
C3-1	Crosslinked (ApSiO ₂ /PAA) ₈	0.93	0.81	70	68
C3-2	Crosslinked (ApSiO ₂ /PAA) _{8.5}	0.76	0.56	76	77

Example 4: ApSiO₂ /PAA coating on Design III stack

25 The procedure is same as in Example 3. An (ApSiO₂/PAA)₁₁ coating was assembled on both sides of the Design III lens, dried and then dipped in a 0.05M MES buffer solution containing EDC (0.2M) and NHS (0.05M) for 1h, and finally rinsed by a PBS solution (0.5x) and air dried. The thickness of the crosslinked coating was about 104 nm and its refractive index was 1.48.

30

Sample	Coating	Rm (%)	Rv (%)	T _r % (EN168)	
				60 s	120 s
C4-1	Crosslinked (ApSiO ₂ /PAA) ₁₁	0.87	0.51	95	94

As shown by Figures 2A and 2B, the optical articles according to the invention have good antifog properties compared to a classical Reference lens.

Also, the optical articles according to the invention have good antireflecting properties in the visible region as demonstrated by their R_m and R_v parameter.

The R_v values for all examples of the inventions are far beneath the upper R_v limit of 2.5% per face required by the International Standard previously referred to.

5 Finally all the optical articles of the invention shown above successfully passed the hand wiping test.

Comparative examples 1-3:

Example 1 (AR design I), 2 (AR design II) and 4 (AR design III) were reproduced, except 10 that a classical antifog coating Visgard™ available from Film Specialties, Inc. was used to replace the LbL coating of the invention.

The Visgard™ coating composition was diluted with solvent glycol ether PM into a solution of 2-3 wt%. The coatings were prepared by spin (800rpm for 5s and 1500rpm for 8s). The thickness was adjusted to the simulated thickness range.

15 The samples were then backed at 126 °C for 1h. After cooling down, the samples were conducted the same tests shown in the previous examples.

Sample	AR Design	Coating thickness (nm)	R _v %	T _r % at 60s (EN168)	Cosmetic	Hand wiping test
CE-1	I	72	0.72	95	Crazed	Failed
CE-2	II	85	0.75	95	Crazed	Failed
CE-3	III	96	0.85	~100	Good	Failed

In general, the lenses CE1 and CE2 appeared severely crazed under visual inspection 20 but CE3 appeared good due to the specifically designed resistance to crazing at high temperature. All lenses showed good antifog and antireflecting performances, but failed in the hand wiping test, indicating bad mechanical properties.

Example 5

25 This example shows how it is possible to control the refractive index of crosslinked LbL coatings used in the invention: by modifying the solvent ratio.

Two (CTS/CMC)₁₀ LbL crosslinked coatings are prepared according to the protocole of example 1, except that the solvent of the crosslinking solution is a blend of H₂O/ethanol in 30 different weight ratios.

The obtained thickness and indices after crosslinking are mentioned in the following table.

(CTS./CMC) ₁₀	Crosslinking solvent	Thickness (nm)	Refractive Index at 634nm
C5-1	H ₂ O/EtOH (60:40wt%)	77	1.46
C5-2	H ₂ O/EtOH (20:80wt%)	61	1.48

CLAIMS

1. An optical article comprising a substrate and on at least one face of the substrate a multilayered antireflecting coating functioning in an interferential manner having antifog properties, said antireflecting coating including a last layer with a refractive index $n \leq 1.55$ and a physical thickness of 120 nm or less directly deposited on a high refractive index layer (HI layer) having a refractive index $n > 1.55$, and a thickness of less than 500 nm, wherein:

- the last layer comprises a layer-by-layer (LbL) coating exposed to environment,
- the LbL coating consists in at least two bilayers, each bilayer being formed by

10 successively

(a) applying a first layer composition comprising at least one compound A having a first electrical charge;

(b) applying a second layer composition directly on the first layer resulting from step (a), said second layer composition comprising at least one compound B having a second electric charge which is opposite to said first electric charge, said compounds A and B being independently chosen from superabsorbent polyelectrolytes, colloid of nanoparticles of metal oxide or silicon oxide, or mixtures thereof, said nanoparticles comprising ionic groups and said compounds A and B being functionalized by either -NH_2 or -COOH functional groups, with the first proviso that at least one of compounds A or B is a superabsorbent polyelectrolyte, and with the second proviso that the layers of the antireflecting coating other than the last layer do not comprise any bilayer formed from compositions having opposite electrical charges, and

- the LbL coating is crosslinked through chemical linkages between said NH_2 and COOH groups and has a refractive index at 643 nm ranging from 1.40 to 1.50

2. An optical article according to claim 1, wherein the superabsorbent polyelectrolyte is a polysaccharide polymer including glucosamine units, a carboxyalkyl cellulose polymer or a polyacrylic acid polymer or polyacrylic acid copolymer.

3. An optical article according to claim 1, wherein the silicon oxide nanoparticles are obtained from silica nanoparticles functionalized with amino groups.

4. An optical article according to claim 1, wherein each bilayer of the LbL coating comprises and preferably consists in:

a) a first layer of a polysaccharide comprising glucosamine units such as chitosan (CTS) or poly(1,3- β -D-glucosamine-alt-1,4- β -D-glucuronic acid), preferably chitosan, and a second layer of a carboxyalkyl cellulose, such as carboxymethyl cellulose, carboxyethyl cellulose or carboxypropyl cellulose, preferably carboxymethyl cellulose (CMC); or

b) a first layer of an oxide of a metal or silicon which is surface functionalized with amine groups, preferably aminopropyl functionalized silica nanoparticles (ApSiO_2), and a second layer of a polymer chosen from PAA, poly(methacrylic acid) (PMAA), PAA copolymer, PMAA copolymer and mixtures thereof, preferably PAA.

5. An optical article according to claim 4, wherein the first layer of the bilayer is made of chitosan and the second layer of the bilayer is made of carboxymethyl cellulose.

6. An optical article according to claim 4, wherein the first layer of the bilayer is made of aminopropyl functionalised silica and the second layer of the bilayer is made of polyacrylic acid.

7. An optical article according to claim 1, wherein the last layer consists entirely in a LbL coating.

5 8. An optical article according to claim 1, wherein the last layer is a composite layer comprising a metal oxide or silicon oxide layer having a refractive index $n \leq 1.55$ underlying a LbL coating as set forth in claim 1.

9. An optical article according to claim 8, wherein the underlying metal oxide or silicon oxide layer has a physical thickness ranging from 10 to 20 nm.

10 10. An optical article according to any one of claims 1 to 9, wherein the LbL coating has a refractive index n ranging from 1.43 to 1.49.

11. An optical article according to any one of claims 1 to 10, wherein the multilayered antireflecting coating further comprises a stack of low refractive index layers (LI layers) having a refractive index $n \leq 1.55$ and high refractive index layers (HI layers) having a refractive index $n > 1.55$.

15 12. An optical article according to claim 11, wherein the LI layers are made of SiO_2 , SiO_x with $1 \leq x < 2$, MgF_2 , ZrF_4 , AlF_3 , chiolite ($\text{Na}_5\text{Al}_3\text{F}_{14}$), cryolite (Na_3AlF_6), mixtures of SiO_2 and/or SiO_x and 10% by weight or less of Al_2O_3 , and mixture thereof;

- the HI layers are made of ZrO_2 , TiO_2 , Ta_2O_5 , Na_2O_5 , Pr_2O_3 , PrTiO_3 , La_2O_3 , Dy_2O_5 ,

20 Nb_2O_5 , Y_2O_3 , mixtures thereof and mixtures of these oxides with silica and/or alumina

13. An optical according to claim 11 or 12, wherein the layers of the stack are deposited through a vacuum evaporation process.

14. An optical article according to any one of claims 1 to 13, wherein the LbL coating comprises 2 to 20 bilayers.

25 15. An optical article according to any one of claims 1 to 14, wherein the optical article is an ophthalmic lens.

16. A process for making a multilayered antifogging antireflecting coating functioning in an interferential manner onto an optical substrate comprising:

(i) providing an uncoated or coated substrate ;

30 (ii) forming on said substrate at least one high refractive index layer (HI layer) having a refractive index $n > 1.55$ and a thickness lower than 500 nm ;

(iii) forming on the HI layer resulting from step (ii) a last layer with a refractive index $n \leq 1.55$ and a physical thickness of 120 nm or less comprising a LbL coating which comprises at least two bilayers, each bilayer being formed by :

35 (a) applying a first layer composition comprising at least one compound A having a first electrical charge;

(b) applying a second layer composition directly on the first layer resulting from step (a), said second layer composition comprising at least one compound B having a second electric charge which is opposite to said first electric charge;

40 compounds A and B being independently chosen from superabsorbent polyelectrolytes,

colloids of nanoparticles of metal oxide or silicon oxide, or mixtures thereof, said nanoparticles comprising ionic groups and said compounds A and B being functionalized by either -NH₂ or -COOH groups with the first proviso that at least one of compounds A or B is a superabsorbent polyelectrolyte, and with the second proviso that the layers of the antireflecting coating other

5 than the last layer do not comprise any bilayer formed from compositions having opposite electrical charges, and

(c) repeating at least once steps (a) and (b),

(d) at least partially drying the LbL coating resulting from step c) and

(e) crosslinking the first and second layers of the bilayers of the LbL coating by

10 treatment with a coupling agent in an aqueous based solvent inducing chemical linkages between said -NH₂ and -COOH groups of compounds A and B, said crosslinking step being performed after step (d), so that the resulting LbL coating has a refractive index at 643 nm ranging from 1.40 to 1.50.

17. A process according to claim 16, wherein the superabsorbent polyelectrolyte is a
15 polysaccharide polymer including glucosamine units, a carboxyalkyl cellulose polymer, or a polyacrylic acid polymer or polyacrylic acid copolymer.

18. A process according to claim 16, wherein the silicon oxide nanoparticles are obtained from silica nanoparticles functionalized with amino groups.

19. A process according to claim 16, wherein each bilayer of the LbL coating comprises
20 and preferably consists in:

a) a first layer of a polysaccharide comprising glucosamine units such as chitosan (CTS) or poly(1,3- β -D-glucosamine-alt-1,4- β -D-glucuronic acid, preferably chitosan, and a second layer of a carboxyalkyl cellulose, such as carboxymethyl cellulose, carboxyethyl cellulose or carboxypropyl cellulose, preferably carboxymethyl cellulose (CMC); or

25 b) a first layer of an oxide of a metal or silicon which is surface functionalized with amine groups, preferably aminopropyl functionalized silica nanoparticles (ApSiO₂), and a second layer of a polymer chosen from PAA, poly(methacrylic acid) (PMAA), PAA copolymer, PMAA copolymer and mixtures thereof, preferably PAA.

20. A process according to claim 16, wherein the last layer consists in a LbL coating.

30 21 A process according to claim 16, wherein the last antifog layer is a composite layer consisting in a layer comprising metal oxide or silicon oxide underlying the LbL coating and is formed by:

a) forming a layer comprising metal oxide or silicon oxide on said HI layer, and
b) forming the LbL coating on the layer resulting from step a).

35 22. A process according to any one of claims 16 to 21 which comprises forming a stack of LI and HI layers prior to forming the last layer on a HI layer of the stack.

23. A process according to claim 22, wherein the LI layers are made of SiO₂, SiO_x with 1 ≤ x < 2, MgF₂, ZrF₄, AlF₃, chiolite (Na₅Al₃F₁₄), cryolite (Na₃AlF₆), mixtures of SiO₂ and/or SiO_x and 10% by weight or less of Al₂O₃, and mixture thereof;

40 - the HI layers are made of ZrO₂, TiO₂, Ta₂O₅, Na₂O₅, Pr₂O₃, PrTiO₃, La₂O₃, Dy₂O₅,

Nb_2O_5 , Y_2O_3 , mixtures thereof and mixtures of these oxides with silica and/or alumina

24. A process according to any one of claims 16 to 23, wherein the layers other than the LbL coating of the antireflecting coating are made by vacuum deposition.

25. A process according to claims 16 to 24, wherein in cross linking step d) the coupling agent comprises a carbodiimide compound, preferably 1-ethyl-3-[3-dimethylaminopropyl]carbodiimide hydrochloride and N-hydroxysuccinimide.

FIGURE 1A

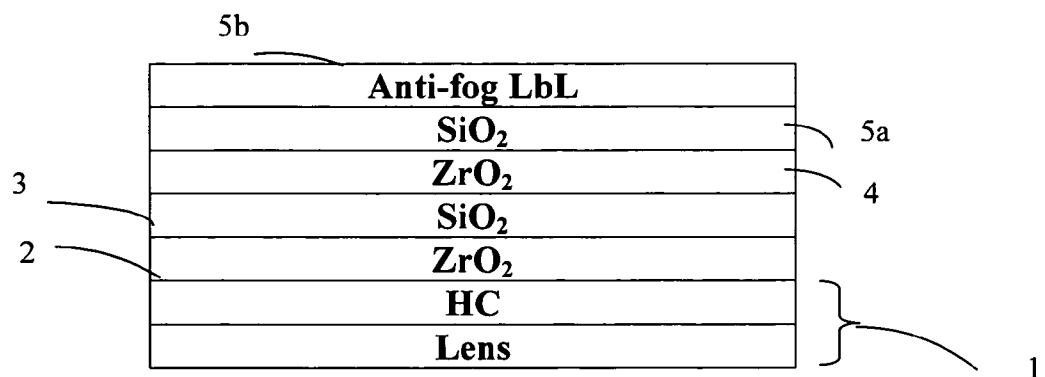


FIGURE 1B

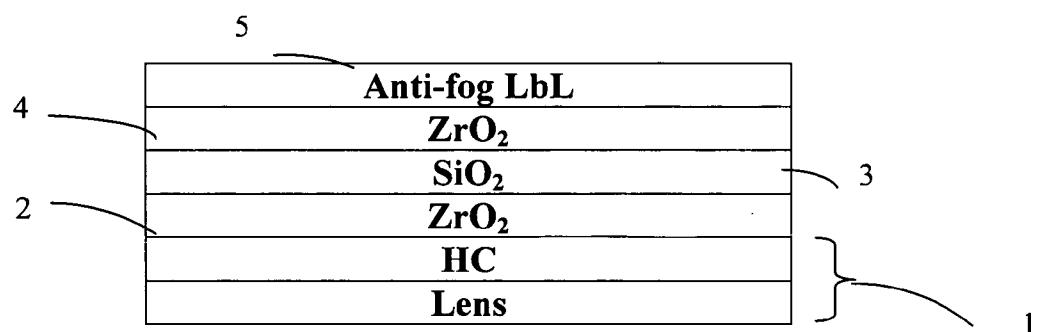
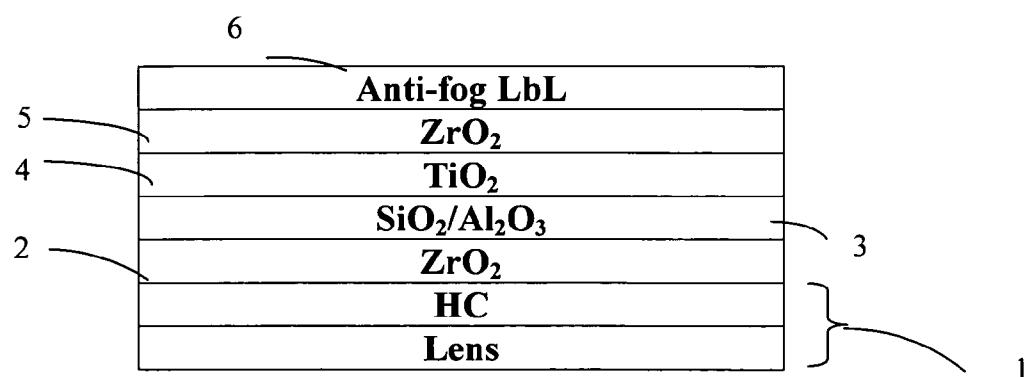


FIGURE 1C



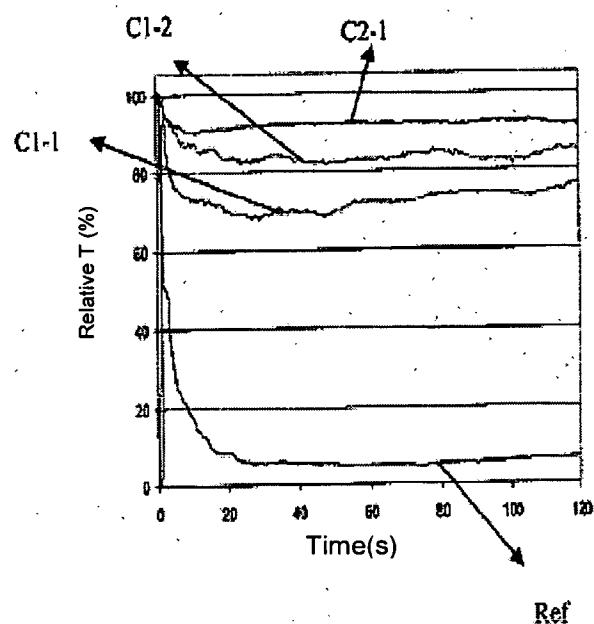


Figure 2A

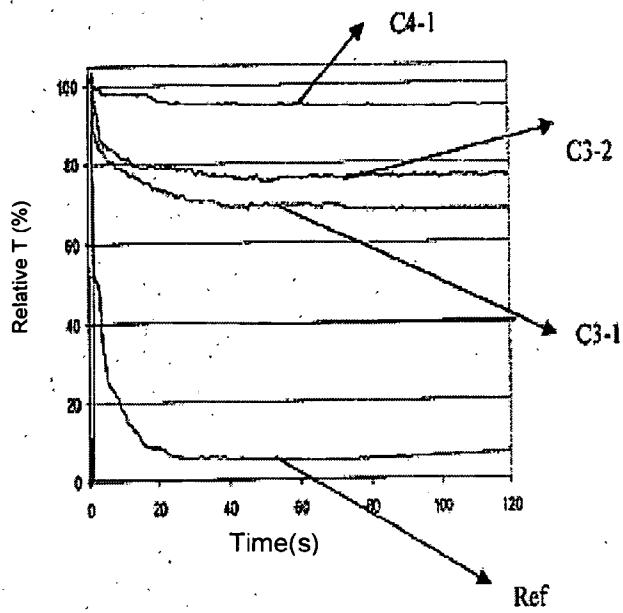


Figure 2B

INTERNATIONAL SEARCH REPORT

International application No

PCT/EP2011/062981

A. CLASSIFICATION OF SUBJECT MATTER

INV. C09D5/16 C09D7/12 B05D7/24 C23C16/40 G02B1/11
G02B27/00

ADD.

According to International Patent Classification (IPC) or to both national classification and IPC

B. FIELDS SEARCHED

Minimum documentation searched (classification system followed by classification symbols)
C09D G02B C09K B05D C23C

Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched

Electronic data base consulted during the international search (name of data base and, where practical, search terms used)

EPO-Internal, WPI Data

C. DOCUMENTS CONSIDERED TO BE RELEVANT

Category*	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
X	WO 2007/056427 A2 (MASSACHUSETTS INST TECHNOLOGY [US]; ZHAI LEI [US]; COHEN ROBERT E [US]) 18 May 2007 (2007-05-18) cited in the application page 15, lines 6-10 figures 5b,5c sentences 23-32 ----- A US 2009/324910 A1 (GEMICI ZEKERIYYA [US] ET AL) 31 December 2009 (2009-12-31) paragraph [0073] paragraphs [0037], [0047] ----- X, P US 2010/304150 A1 (ZHENG HAIPENG [US] ET AL) 2 December 2010 (2010-12-02) paragraphs [0171] - [0173] ----- -/-	1-25 1-25 1-25 -/-

Further documents are listed in the continuation of Box C.

See patent family annex.

* Special categories of cited documents :

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"O" document referring to an oral disclosure, use, exhibition or other means
"P" document published prior to the international filing date but later than the priority date claimed

"T" later document published after the international filing date or priority date and not in conflict with the application but cited to understand the principle or theory underlying the invention
"X" document of particular relevance; the claimed invention cannot be considered novel or cannot be considered to involve an inventive step when the document is taken alone
"Y" document of particular relevance; the claimed invention cannot be considered to involve an inventive step when the document is combined with one or more other such documents, such combination being obvious to a person skilled in the art.
"&" document member of the same patent family

Date of the actual completion of the international search

20 September 2011

Date of mailing of the international search report

29/09/2011

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INTERNATIONAL SEARCH REPORT

International application No PCT/EP2011/062981

C(Continuation). DOCUMENTS CONSIDERED TO BE RELEVANT

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INTERNATIONAL SEARCH REPORT

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International application No

PCT/EP2011/062981

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